ABSTRACT

RETICLE SYSTEM FOR MANUFACTURING INTEGRATED CIRCUIT SYSTEMS

A reticle system that includes: providing a reticle system; and assigning two or more of an image pattern onto the reticle system to form one or more layers of an integrated circuit system by grouping and pairing each of the image pattern onto the reticle system according to a multi-layer reticle grouping/pairing flow.

Fig. 7